## Au nanocone array with 3D hotpots for biomarker chip

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**Figure S1.** Figure a is a PS beads etched for 3 min with a diameter of 420 nm. Figure B is the base obtained by adhesive tape with PS beads. Figure c shows the substrate formed by the nanohole array as the inclined nanocone array.



**Figure S2.** (a)  $S_{1L}$  indicates the length of the pyramid.  $S_{2G}$  indicates the height of the triangle cone.  $Z_{1L}$  indicates column length.  $Z_{2G}$  indicates column height.  $J_2$  represents the column spacing of 40° sputtering. J is the distance from the surrounding nanocone to the central column. (b)Nanocone array gap distance.



Figure S3. The Au nanocone arrays in groups A and B were tilted at 60° and 20°, respectively.  $a_1$ - $f_1$  is the structure diagram of gold nanocone sputtering with an inclination of  $60^\circ$  for 0-5 min.  $a_2$  is the structure diagram of gold nanocone sputtering at an Angle of  $20^{\circ}$  for 2 min.



**Figure S4.** Raman spectra of the 60° and 20° tilted gold nanocone arrays (a and b), and the sputtering time is 1-8 min.



**Figure S5.** Mean electric field intensity for  $20^\circ$ ,  $40^\circ$ ,  $60^\circ$  gold nanocone array at the Au tip (a) and at the Au gap (b).



**Figure S6.** Electric field analysis diagram of Au nanocone array at 20°, 40°, 60°.